## Direct Determination of the Chemical Bonding of Individual Impurities in Graphene.

Myron D. Kapetanakis<sup>1,2</sup>, Wu Zhou<sup>1,2</sup>, Micah P. Prange<sup>1,2,\*</sup>, Sokrates T. Pantelides<sup>1,2</sup>, Stephen J. Pennycook<sup>2,1</sup>, Juan-Carlos Idrobo<sup>2</sup>

<sup>1</sup>Department of Physics and Astronomy, Vanderbilt University, Nashville, Tennessee 37235, USA

<sup>2</sup>Materials Science and Technology Division, Oak Ridge National Laboratory, Oak Ridge, Tennessee 37831, USA

\*Present address: Pacific Northwest National Laboratory, Richland, WA 99352, USA.

## Abstract

Using a combination of Z-contrast imaging and atomically resolved electron energy-loss spectroscopy on a scanning transmission electron microscope, we show that the chemical bonding of individual impurity atoms can be deduced experimentally. We find that when a Si atom is bonded with four atoms at a double-vacancy site in graphene, Si 3d orbitals contribute significantly to the bonding, resulting in a planar sp<sup>2</sup>d-like hybridization, whereas threefold coordinated Si in graphene adopts the preferred sp<sup>3</sup> hybridization. The conclusions are confirmed by first-principles calculations as implemented in the Vienna Ab initio Simulation Package and demonstrate that chemical bonding of two-dimensional materials can now be explored at the single impurity level<sup>1</sup>.

## Acknowledgment

This research was supported by NSF (DMR-0938330) (WZ), ORNL's (ShaRE) User Program (JCI), which is sponsored by the Office of BES, U.S. DoE, the MSE Division, Office of BES, U.S. DoE (SJP, STP), and DoE (DE-FG02-09ER46554) (MDK, MPP, STP). This research used resources of the NERSC, which is supported by the Office of Science of the U.S. DoE (DE-AC02-05CH11231).

[1] Wu Zhou, Myron D. Kapetanakis, Micah P. Prange, Sokrates T. Pantelides, Stephen J. Pennycook, Juan-Carlos Idrobo, *Phys Rev Lett*, **109**, 206803 (2012).